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Control of MXenes' electronic properties through termination and intercalation

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MXenes are an emerging family of highly-conductive 2D materials which have demonstrated state-of-the-art performance in electromagnetic interference shielding, chemical sensing, and energy storage. To further improve performance, there is a need to increase MXenes' electronic conductivity. Tailoring the MXene surface chemistry could achieve this goal, as density functional theory predicts that surface terminations strongly influence MXenes' Fermi level density of states and thereby MXenes' electronic conductivity. Here, we directly correlate MXene surface de-functionalization with increased electronic conductivity through in situ vacuum annealing, electrical biasing, and spectroscopic analysis within the transmission electron microscope. Furthermore, we show that intercalation can induce transitions between metallic and semiconductor-like transport (transitions from a positive to negative temperature-dependence of resistance) through inter-flake effects. These findings lay the groundwork for intercalation- and termination-engineered MXenes, which promise improved electronic conductivity and could lead to the realization of semiconducting, magnetic, and topologically insulating MXenes.

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Discovered in 2011, MXenes are a rapidly growing family of 2D transition metal carbides, nitrides, and carbonitrides with the general formula $M_{n+1}X_nT_x$ ($n = 1, 2, \text{ or } 3$; $M = \text{transition metal, e.g., Ti, V, Nb, Mo}$; $X = \text{C and/or N}$; $T = \text{surface termination, e.g., } -\text{OH, } -\text{F, } =\text{O}$)^{1–5}. MXenes are formed by selective etching parent ternary carbide MAX compounds to remove the A-group element, e.g., Ti_3AlC_2 (layered MAX) \rightarrow $\text{Ti}_3\text{C}_2\text{T}_x$ (2D MXene)^{6,7}. For both device applications and fundamental studies, MXene samples are generally thin films comprised of many MXene flakes, though some studies have focused on single-layer MXene^{8,9}. In contrast to most other 2D materials, MXenes offer an attractive combination of high electronic conductivity, hydrophilicity, and chemical stability^{1–5,10–13}. With these properties, MXenes show exceptional promise in areas including electromagnetic interference shielding^{14,15}, wireless communication¹⁶, chemical sensing^{17–20}, energy storage^{21–23}, optoelectronics^{24–27}, triboelectrics^{28–30}, catalysis^{31–33}, and conformal/wearable electronics³⁴. Performance in these applications is directly related to electronic conductivity, and as such, there is motivation to further increase the MXene metallic conductivity. In parallel, there is excitement surrounding the potential realization of semiconducting MXenes, which are predicted to be excellent materials for spintronics and thermoelectrics^{35–37}.

To meet these demands on MXenes' electronic properties, researchers have mostly focused on the development of new $M_{n+1}X_n$ chemistries. So far, over 30 MXenes have been synthesized, but the first discovered MXene— $\text{Ti}_3\text{C}_2\text{T}_x$ —remains the most conductive¹³. Recently, certain Mo- and V-based MXenes have garnered interest due to their so-called semiconductor-like behavior^{38–40}, i.e., a negative temperature-dependence of resistance (dR/dT). However, the cause of negative dR/dT in these MXenes remains unclear, and their underlying electronic structure is debated^{38,41}. A potentially more useful approach to control MXenes' conductivity is to manipulate their surface chemistry. Surface terminations, which are introduced during MXene synthesis⁶, have been predicted to control metal-to-insulator transitions^{37,38} and to affect functional properties such as magnetism^{1,42}, Li-ion capacity⁴³, catalytic performance^{31,44}, band alignment⁴⁵, mechanical properties⁴⁶, and predictions of superconductivity⁴⁷. While promising, these predicted effects lack direct experimental confirmation^{48,49}. An additional mechanism which can affect MXene conductivity is intercalation. Intercalants are not thought to alter the intra-flake (intrinsic) MXene properties, but for multi-layer samples, intercalation can increase device resistance by over an order of magnitude^{27,40,41,50–52}. This effect is generally attributed to intercalants increasing the inter-flake spacing and thereby the inter-flake resistance.

For any multi-layer MXene sample, intercalation, termination, and $M_{n+1}X_n$ chemistry all contribute to the measured electronic conductivity, and this convolution of effects greatly complicates experimental interpretation. As a result, our understanding and ability to control MXenes' electronic properties are lacking. To address this challenge, we perform in situ vacuum annealing (up

to 775 °C) and electrical biasing of MXenes within the transmission electron microscope (TEM). We observe de-intercalation and surface de-functionalization with in situ electron energy loss spectroscopy (EELS) and ex situ thermogravimetric analysis with mass spectroscopy (TGA-MS). Importantly, we utilize low-dose direct detection (DD) EELS⁵³ to avoid electron beam-induced specimen damage⁵⁴ (Supplementary Figure 1). With this approach, we correlate the desorption of $-\text{OH}$, $-\text{F}$, and $=\text{O}$ termination species with increased MXene conductivity. Additionally, we report transitions from ensemble semiconductor-like (negative dR/dT) to metallic behavior in Ti_3CNT_x and $\text{Mo}_2\text{TiC}_2\text{T}_x$ after the de-intercalation of water and organic molecules. This work furthers our fundamental understanding of conduction through MXene films and opens the door to intercalation- and termination-engineered MXenes.

Results

Sample synthesis and experimental approach. We investigated three MXenes with diverse macroscopic electronic transport behavior: $\text{Ti}_3\text{C}_2\text{T}_x$, Ti_3CNT_x , and $\text{Mo}_2\text{TiC}_2\text{T}_x$ (Table 1). $\text{Ti}_3\text{C}_2\text{T}_x$ (its structure is shown schematically in the Fig. 1a top inset) is the most studied MXene and is known to be metallic and highly conductive⁷. Density functional theory (DFT) studies have consistently predicted that surface functionalization reduces the $\text{Ti}_3\text{C}_2\text{T}_x$ density of states (DOS) at the Fermi level (E_F), suggesting a decrease in the charge carrier density and thereby a decrease in the conductivity^{43,55,56}. Understanding of the next two MXenes— Ti_3CNT_x and $\text{Mo}_2\text{TiC}_2\text{T}_x$ —is limited. The structure of Ti_3CNT_x is similar to $\text{Ti}_3\text{C}_2\text{T}_x$ but with a mixture of C and N on the X-sites (Fig. 1b top inset). DFT predicts Ti_3CNT_x to be metallic for all terminations^{55,57,58}, but to date, this MXene has only shown semiconductor-like transport (unpublished results). $\text{Mo}_2\text{TiC}_2\text{T}_x$ is an ordered, double transition metal MXene analogous to $\text{Ti}_3\text{C}_2\text{T}_x$ but with the outer Ti layers replaced by Mo layers⁵⁹ (Fig. 1c top inset). Terminations have been predicted to induce metallic, semiconducting³⁸, and topologically insulating⁶⁰ states in this MXene. Experimentally, $\text{Mo}_2\text{TiC}_2\text{T}_x$ shows semiconductor-like behavior in its as-prepared state³⁸, but it is unclear if this behavior is due to intrinsic ($M_{n+1}X_n$ stoichiometry) or extrinsic (intercalation, inter-flake hopping) effects.

We produced the $\text{Ti}_3\text{C}_2\text{T}_x$ and Ti_3CNT_x samples through etching of their 3D parent MAX phases, i.e., Ti_3AlC_2 and Ti_3AlCN , in a mixture of LiF and HCl. This process results in $-\text{OH}$, $-\text{F}$, and $=\text{O}$ terminations and H_2O and Li^+ intercalation^{6,23}. $\text{Mo}_2\text{TiC}_2\text{T}_x$ was instead produced through etching of $\text{Mo}_2\text{TiAlC}_2$ in HF and delaminating via tetrabutylammonium hydroxide (TBAOH) intercalation⁵⁹. This method reduces the concentration of $-\text{F}$ termination and results in tetrabutylammonium (TBA^+) and H_2O intercalation^{40,61}. TBA^+ is a large organic ion which can significantly increase the inter-flake spacing and electrical resistance^{6,40,52}. To directly compare H_2O and TBA^+ intercalation, we additionally studied Ti_3CNT_x

Table 1 Summary of in situ heating and biasing results

MXene chemistry	Termination	Intercalation	dR/dT	Resistance (Ω)
$\text{Ti}_3\text{C}_2\text{T}_x$	$(\text{OH})_{0.4}\text{F}_{0.4}\text{O}_{0.5} \rightarrow \text{F}_{0.2}\text{O}_{0.5}$	H_2O , $\text{Li}^+ \rightarrow \text{Li}^+$	$\text{M} \rightarrow \text{M}$	$41 \rightarrow 10$
Ti_3CNT_x	$(\text{OH})_{0.9}\text{F}_{0.5}\text{O}_{0.7} \rightarrow \text{F}_{0.2}\text{O}_{0.7}$	H_2O , $\text{Li}^+ \rightarrow \text{Li}^+$	$\text{S} \rightarrow \text{M}$	$159 \rightarrow 27$
$\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$	$(\text{OH})_{0.6}\text{F}_{0.1}\text{O}_{1.2} \rightarrow \text{O}_{1.2}$	H_2O , $\text{TBA}^+ \rightarrow \text{none}$	$\text{S} \rightarrow \text{S}$	$3330 \rightarrow 290$
$\text{Mo}_2\text{TiC}_2\text{T}_x$	$(\text{OH})_{0.5}\text{F}_{0.01}\text{O}_{1.5} \rightarrow \text{O}_{0.8}$	H_2O , $\text{TBA}^+ \rightarrow \text{none}$	$\text{S} \rightarrow \text{M}$	$2500 \rightarrow 387$

In each cell, the arrow symbol represents changes induced during in situ vacuum annealing up to temperatures of 775, 700, 750, and 775 °C for $\text{Ti}_3\text{C}_2\text{T}_x$, Ti_3CNT_x , $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$, and $\text{Mo}_2\text{TiC}_2\text{T}_x$, respectively. In the dR/dT column, M indicates metallic conduction (positive dR/dT) while S indicates semiconductor-like conduction (negative dR/dT). Initial termination concentrations were determined through ex situ X-ray photoelectron spectroscopy (XPS) measurements (Supplementary Tables 3–6 and Supplementary Figure 12). The loss of intercalants and $-\text{OH}$ terminations was determined from ex situ TGA-MS, and the reduction in $-\text{F}$ and $=\text{O}$ terminating species was measured with in situ EELS

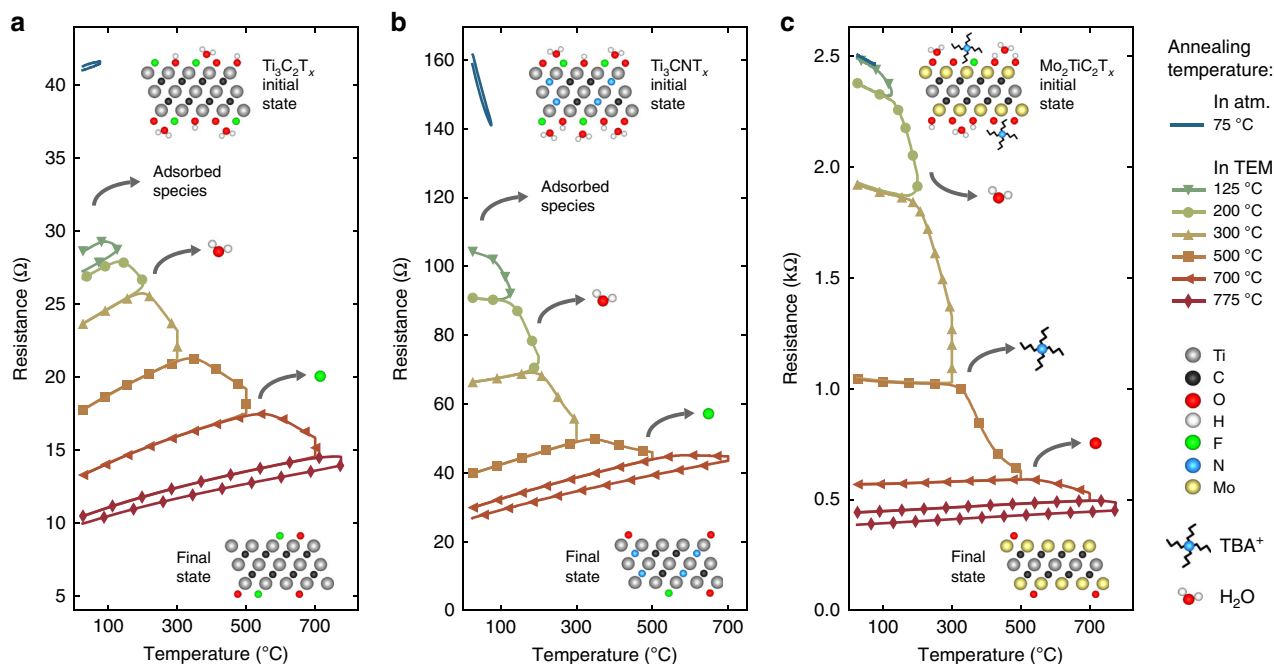


Fig. 1 Evolution of MXene electronic properties with in situ vacuum annealing. Resistance versus temperature measurements are shown for $\text{Ti}_3\text{C}_2\text{T}_x$ (a), Ti_3CNT_x (b), and $\text{Mo}_2\text{TiC}_2\text{T}_x$ (c). The measurements were conducted during various vacuum annealing steps performed in the TEM. Each vacuum annealing step is represented with a different color and symbol. For each annealing step, both the heating and cooling curves are shown. In all cases, the resistance decreased during annealing, hence, the cooling curve is always beneath the heating curve. The atomic structures of the various MXenes are shown as insets. The initial state schematics (top schematics) show $\text{Ti}_3\text{C}_2\text{T}_x$ and Ti_3CNT_x with intercalated water molecules on their surfaces, and $\text{Mo}_2\text{TiC}_2\text{T}_x$ is shown with water and TBA⁺ molecules. With annealing, the MXene sample resistance is affected by the loss of adsorbed species, intercalants, and terminating species. Some of these processes are shown schematically. The resistance data in this figure are also shown in Supplementary Figures 13–15, where the resistance is plotted as a function of annealing time

prepared with HF etching and TBAOH delamination. For clarity, this sample is referred to as $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$.

After synthesis, MXene films were spray-casted²⁴ onto MEMS (microelectromechanical systems)-based nanochips⁶² designed for heating and biasing within the TEM column (Supplementary Figure 2). The MXene films were at least several flakes thick (Supplementary Figures 1 and 2), and the electrode spacing (~20 μm) was considerably larger than the MXene flake diameters (~100 nm up to 2–3 μm). As such, sample resistance measurements were dependent upon both intra- and inter-flake contributions. The cross-sectional sample areas were not well-defined, so we report the relative change in sample resistance and not the absolute resistivity. TEM imaging and electron diffraction confirmed the MXene structure both before and after in situ annealing at ≥ 700 °C (Supplementary Figure 2).

The temperature-dependent resistance of each sample was initially measured in ambient atmosphere from room temperature (RT) up to 75 °C in order to understand the as-prepared sample properties. In agreement with previous results, $\text{Ti}_3\text{C}_2\text{T}_x$ displayed metallic behavior while Ti_3CNT_x and $\text{Mo}_2\text{TiC}_2\text{T}_x$ displayed semiconductor-like (negative dR/dT) behavior^{27,38} (Table 1 and Fig. 1). After measurement of the as-prepared MXene electronic properties, the samples were inserted into the TEM and vacuum annealed at temperatures up to 775 °C.

Before providing a detailed analysis of our in situ heating and biasing experiments, we first summarize our two main findings. First, we observed transitions from semiconductor-like to metallic behavior in Ti_3CNT_x and $\text{Mo}_2\text{TiC}_2\text{T}_x$ after the annealing-induced loss of intercalated species. These transitions reveal the intra-flake metallicity of Ti_3CNT_x and $\text{Mo}_2\text{TiC}_2\text{T}_x$ and demonstrate that intercalants can cause negative dR/dT in multi-layer MXenes. Second, high temperature annealing and the partial loss of surface

terminations (Fig. 1, bottom insets) increased the conductivity of all three MXenes. This finding is in agreement with past predictions that non-terminated MXenes exhibit metallic behavior with high carrier concentrations^{43,55,56,59}. In the following, we describe the in situ heating and biasing data in greater detail; results are organized based on the different mechanisms which influence MXene electronic properties.

Adsorbed species. Prior to thermal annealing, insertion of $\text{Ti}_3\text{C}_2\text{T}_x$ and Ti_3CNT_x into the TEM vacuum ($\sim 10^{-5}$ Pa) caused an immediate reduction in resistance (Fig. 1a, b and Supplementary Figure 3). For both of these samples, the resistance decreased roughly 20% after 150 s of insertion into the TEM. This change in resistance is attributed to the loss of adsorbed atmospheric species, e.g., H_2O and O_2 . These species are known to cause doping in 2D materials such as graphene⁶³, and similar effects have previously been reported in $\text{Ti}_3\text{C}_2\text{T}_x$ ^{8,25}. We note that both of these samples were only intercalated with H_2O and Li^+ . For $\text{Mo}_2\text{TiC}_2\text{T}_x$ intercalated with TBA⁺, the sample resistance did not significantly change upon exposure to the TEM vacuum (Fig. 1c and Supplementary Figure 3). This observation suggests an increased effect of the large TBA⁺ molecule relative to H_2O , specifically, that TBA⁺ intercalation limits the film resistance and masks the effect of atmospheric species desorption on the electronic resistance. The effect of adsorbed species on the resistance of $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$ could not be determined, since the sample resistance prior to in situ vacuum annealing was too high to be accurately measured.

Intercalation. For all studied MXenes, de-intercalation significantly increased electronic conductivity. We first consider the

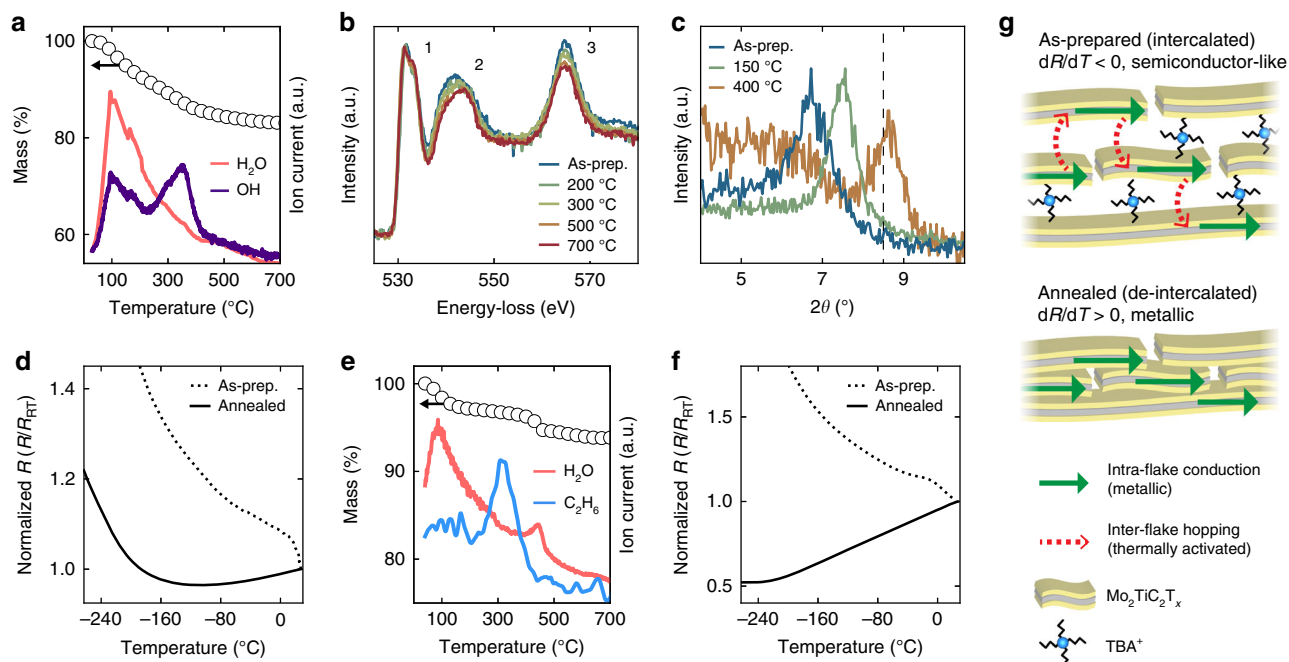


Fig. 2 Influence of intercalated species on the MXene resistance and dR/dT . **a** TGA-MS of Ti_3CNT_x showing the loss of H_2O intercalants and $-\text{OH}$ termination species. **b** In situ EELS of the normalized O K -edge of Ti_3CNT_x indicating the loss of H_2O intercalants with annealing. **c** Ex situ XRD of the Ti_3CNT_x (002) peak for an as-prepared thick sample, i.e., vacuum filtered and free-standing, as well as thick samples annealed at 150°C (in vacuum) and 400°C (in Ar). The peak shift to higher 2θ values represents a decrease in the inter-layer spacing. The dashed vertical line represents the approximate position of the $\text{Ti}_3\text{C}_2\text{T}_x$ (002) peak after annealing at 150°C , taken from ref. ⁶. **d** Temperature-dependent PPMS resistance measurements of a thick as-prepared (intercalated) Ti_3CNT_x sample and the de-intercalated sample annealed to 700°C within the TEM. R_{RT} is the room temperature resistance. **e** TGA-MS of $\text{Mo}_2\text{TiC}_2\text{T}_x$ showing the loss of H_2O intercalants and the decomposition of TBA^+ intercalants. **f** Temperature-dependent PPMS resistance measurements of a thick as-prepared (intercalated) $\text{Mo}_2\text{TiC}_2\text{T}_x$ sample and the de-intercalated sample annealed to 775°C within the TEM. The as-prepared data is taken from ref. ³⁸. **g** Schematic of intercalants' influence on conduction through multi-flake $\text{Mo}_2\text{TiC}_2\text{T}_x$.

role of H_2O , which began to de-intercalate at lower temperatures than TBA^+ . For all samples, mass spectroscopy (MS) showed a large peak in the H_2O (mass to charge ratio (m/e) = 18) ion current centered at $\sim 150^\circ\text{C}$, indicating H_2O de-intercalation. This behavior is shown for Ti_3CNT_x in Fig. 2a, and full TGA-MS results for all samples are presented in Supplementary Figure 4. In situ EELS data is consistent with the de-intercalation of H_2O during low temperature annealing. Figure 2b shows the O K -edge of Ti_3CNT_x after various in situ annealing steps; three distinct peaks are observed. For $=\text{O}$ or $-\text{OH}$ bonded with surface Ti, these three peaks are expected, with peak 1 arising due to hybridization between the termination moiety and the Ti $3d$ orbitals⁶⁴. Conversely, the O K -edge of water does not contain peak 1⁶⁵. With annealing, peaks 2 and 3 decrease with respect to peak 1, signifying the loss of intercalated H_2O . The loss of $=\text{O}$ or $-\text{OH}$ terminations cannot explain the observed changes in fine structure, as surface de-functionalization would produce a more uniform decrease in the O K -edge intensity.

By annealing samples at 200°C , we isolate the influence of H_2O de-intercalation on the $\text{Ti}_3\text{C}_2\text{T}_x$ and Ti_3CNT_x electronic properties from any effects of surface de-functionalization. To prove this point, we consider the de-functionalization of $-\text{OH}$, the least stable termination species and thus the first to desorb^{12,66}. The MS $-\text{OH}$ ($m/e = 17$) ion current in Fig. 2a shows two peaks for Ti_3CNT_x . The first peak perfectly mirrors the H_2O ion current and is thus attributed to de-protonated H_2O (Supplementary Figure 4); the second peak at $\sim 375^\circ\text{C}$ is attributed to $-\text{OH}$ termination loss. Our conclusion that $-\text{OH}$ terminations are stable at $<200^\circ\text{C}$ is supported by nuclear magnetic resonance spectroscopy and neutron scattering studies performed previously on $\text{Ti}_3\text{C}_2\text{T}_x$ ^{67,68}, assuming that

the termination interaction with surface Ti atoms is similar in both carbide and carbonitride MXenes. Moreover, it was shown that hydroxyl groups do not desorb from titania powder until $350\text{--}500^\circ\text{C}$ ⁶⁹.

For 200°C annealed $\text{Ti}_3\text{C}_2\text{T}_x$, H_2O de-intercalation caused an 18% reduction in sample resistance, in qualitative agreement with past results (Fig. 1a)^{50,70}. Subtle increases in the dR/dT of $\text{Ti}_3\text{C}_2\text{T}_x$ with 125 and 200°C annealing suggest the decrease of an insulating inter-flake resistive term, as opposed to a change in the intra-flake metallic conductivity (Supplementary Note 1, Supplementary Figure 5, and Supplementary Table 1). These changes in dR/dT with low temperature annealing are in agreement with a decrease in resistance driven by H_2O de-intercalation.

In comparison to $\text{Ti}_3\text{C}_2\text{T}_x$, Ti_3CNT_x displayed an anomalously large response to H_2O de-intercalation. After annealing at 200°C , there was a 36% decrease in resistance and a transition from negative to positive dR/dT (Fig. 1b). Ex situ XRD shows a contraction of the Ti_3CNT_x c -lattice parameter (signifying a decrease in the inter-layer spacing) after 150°C annealing (Fig. 2c). This measurement further confirms the partial de-intercalation of water and supports the argument that de-intercalation improves conductivity through a reduced inter-flake resistance.

The measurement of metallic conductivity in Ti_3CNT_x confirms numerous theoretical predictions of its metallic nature^{55,57,58}. To better understand the electronic properties of the de-intercalated Ti_3CNT_x , we studied the sample's low-temperature conduction ex situ. To do so, the sample was further annealed to 700°C (ensuring maximum de-intercalation), removed from the TEM, and then inserted into the physical property measurement system (PPMS). Figure 2d shows the

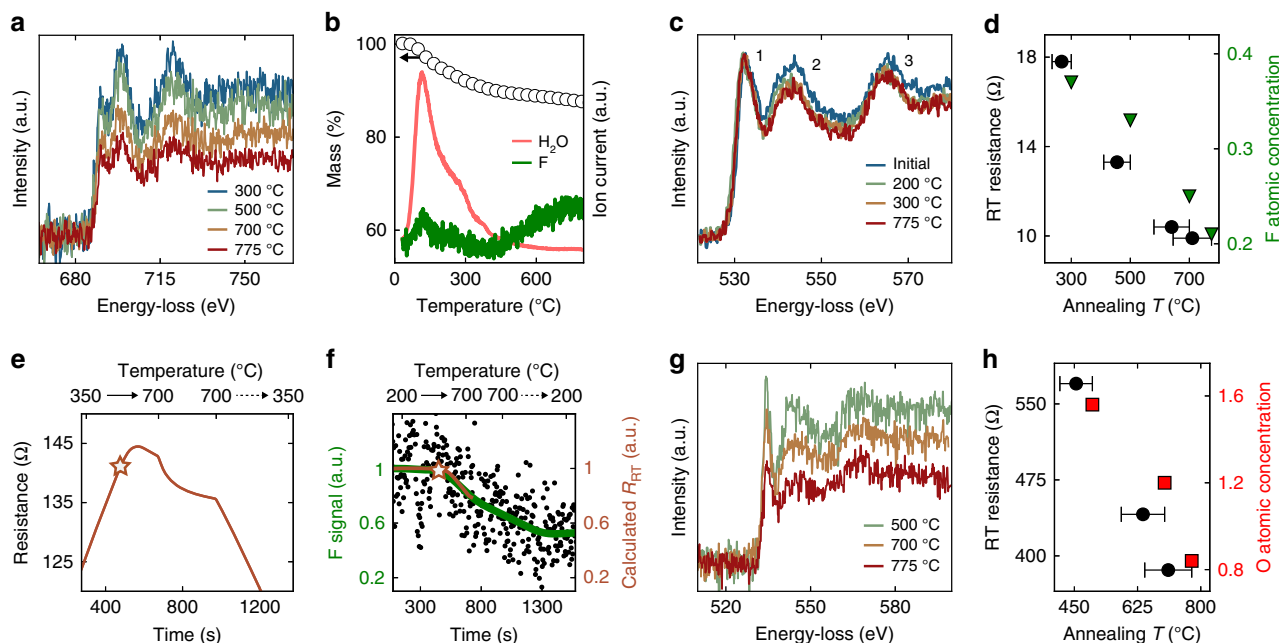


Fig. 3 Correlation of MXene surface termination and conductivity. **a** In situ EELS of the $\text{Ti}_3\text{C}_2\text{T}_x$ F K-edge showing the loss of $-\text{F}$ with annealing. **b** TGA-MS of $\text{Ti}_3\text{C}_2\text{T}_x$ showing de-intercalation of H_2O completing by $\sim 400^\circ\text{C}$ and the onset of $-\text{F}$ de-functionalization at $\sim 400^\circ\text{C}$. **c** In situ EELS of the $\text{Ti}_3\text{C}_2\text{T}_x$ O K-edge with annealing. The relative decrease in peaks 2 and 3 relative to peak 1 indicates the loss of intercalated H_2O and the retention of $=\text{O}$. **d** Comparison of the post-anneal RT resistance of $\text{Ti}_3\text{C}_2\text{T}_x$ (black circles) and $-\text{F}$ concentration (green triangles) given in units of x based on the chemical formula $\text{Ti}_3\text{C}_2\text{O}_{0.5}\text{F}_x$. **e, f** show the time-resolved resistance and F K-edge intensity, respectively, of Ti_3CNT_x during in situ annealing. The solid (dashed) arrows represent heating (cooling). For the time axis, $t = 0$ s corresponds to the beginning of annealing at RT. The stars mark 500°C , the maximum temperature of prior annealing. The green line in **f** is a Gaussian smooth of the EELS data (black circles). The dark orange line in **f** is the calculated RT resistance, determined using the measured value of dR/dT upon heating. Because dR/dT changes with annealing, this calculation is only valid up to $\sim 700^\circ\text{C}$. To highlight the correlation between the $-\text{F}$ concentration and the calculated RT resistance, both quantities were normalized by their initial value. **g** In situ EELS spectra of the O K-edge of $\text{Mo}_2\text{TiC}_2\text{T}_x$. **h** Comparison of the post-anneal RT resistance (black circles) with the concentration of $=\text{O}$ (red squares), given in units of x based on the chemical formula $\text{Mo}_2\text{TiC}_2\text{O}_x$. For **a, c, and g**, EELS spectra were acquired at RT after annealing, and the edge intensities were normalized to the Ti L-edge intensity. In **d** and **h**, the change in elemental concentration was determined with in situ EELS. The temperature offset between elemental concentration data and resistance measurements in **d** and **h** are due to thermal gradients within the nanochip (Supplementary Figure 10). The range of these thermal gradients are represented by the horizontal error bars in the RT resistance data

normalized resistance of as-prepared (intercalated) and 700°C annealed (de-intercalated) Ti_3CNT_x . The intercalated sample shows semiconductor-like behavior across the entire temperature range of the PPMS measurement (from RT to -263°C), while the de-intercalated sample displays metallic behavior down to roughly -150°C . At this temperature, the de-intercalated Ti_3CNT_x sample shows a transition to negative dR/dT , which is similar to the reported behavior of multi-layer $\text{Ti}_3\text{C}_2\text{T}_x$ samples^{27,38}. It is an open question whether this low temperature transition is due to intra-flake or inter-flake effects. Both the as-prepared and annealed samples displayed negative magnetoresistance (MR) at -263°C (10 K) (Supplementary Figure 6). We note that annealing Ti_3CNT_x above 300°C causes partial surface de-functionalization, which we discuss in the next section. However, high temperature annealing and surface de-functionalization did not significantly affect dR/dT (Fig. 1b and Supplementary Table 1), so we ascribe the changes in normalized resistance shown Fig. 2d to de-intercalation.

While H_2O intercalation was known to increase MXene resistance values, the findings shown in Figs. 1a, b and 2a–d demonstrate that H_2O intercalation can additionally act to decrease the value of dR/dT . Moreover, given a sufficient concentration of intercalants in Ti_3CNT_x , the inter-flake resistance can mask the MXene's intra-flake metallic conductivity. We stress that the resulting negative dR/dT of intercalated Ti_3CNT_x is not due to a bandgap opening, rather it is the

consequence of the temperature-dependence of the inter-flake electron hopping process.

It is noteworthy that H_2O intercalated $\text{Ti}_3\text{C}_2\text{T}_x$ displayed metallic conduction while H_2O intercalated Ti_3CNT_x displayed semiconductor-like conduction, despite both MXenes being intrinsically metallic. To understand this difference, we show the position of the $\text{Ti}_3\text{C}_2\text{T}_x$ (002) peak after annealing at 150°C (vertical dashed line in Fig. 2c). The c -lattice spacing of 150°C -annealed Ti_3CNT_x (23.0 \AA) is significantly larger than that of 150°C -annealed $\text{Ti}_3\text{C}_2\text{T}_x$ (20.6 \AA). The lattice spacing of Ti_3CNT_x only contracts to $\sim 20 \text{ \AA}$ after annealing at 400°C . This data suggests an increased lattice response of Ti_3CNT_x to intercalated H_2O , which in turn increases the inter-flake resistance and drives the transition to negative dR/dT .

Measurements of $\text{Mo}_2\text{TiC}_2\text{T}_x$, having both H_2O and TBA^+ intercalants, showed an increased effect of TBA^+ relative to H_2O . Annealing $\text{Mo}_2\text{TiC}_2\text{T}_x$ at 200°C led to the de-intercalation of H_2O and a 24% reduction in resistance, but there was no change in the sign of dR/dT (Figs. 1c and 2e). Subsequent annealing up to 500°C led to a 69% decrease in resistance and a transition from negative to positive dR/dT (Fig. 1c). This transition to metallic behavior is due to the decomposition and loss of TBA^+ , as seen in the MS signal of C_2H_6 ($m/e = 30$) (Fig. 2e). The measured temperature of TBA^+ de-intercalation/decomposition was $\sim 350^\circ\text{C}$, which is similar to the decomposition temperature of TBA^+ intercalated in graphite⁷¹. Previous work has shown that annealing

$\text{Mo}_2\text{TiC}_2\text{T}_x$ at 530 °C reduces the *c*-lattice parameter from 37.7 to 24.5 Å⁵², which supports our claim that the decomposition of TBA^+ causes a decrease in the inter-flake resistance and consequently a transition to metallic behavior.

To further study the effect of TBA^+ decomposition, the low-temperature resistance of $\text{Mo}_2\text{TiC}_2\text{T}_x$ was measured. We annealed the sample up to 775 °C in an attempt to eliminate residual TBA^+ , and then we removed the sample from the TEM and inserted it into the PPMS. The normalized resistance of the as-prepared (intercalated) and the annealed (de-intercalated) $\text{Mo}_2\text{TiC}_2\text{T}_x$ are shown in Fig. 2f. The de-intercalated $\text{Mo}_2\text{TiC}_2\text{T}_x$ sample shows metallic behavior down to the lowest measured temperature of -263 °C (10 K), and both the as-prepared and de-intercalated samples show positive MR (Supplementary Figure 6). These results demonstrate the intrinsically metallic nature of $\text{Mo}_2\text{TiC}_2\text{T}_x$, in agreement with the previously reported metallic conductivity in this MXene after annealing at ~530 °C⁵². We note that annealing $\text{Mo}_2\text{TiC}_2\text{T}_x$ at 775 °C leads to the partial loss of termination groups; however, annealing at these high temperatures did not significantly alter the value of dR/dT (Fig. 1c and Supplementary Table 1). Thus, the difference in normalized resistance shown in Fig. 2f is attributed to de-intercalation.

The observation of intercalation-induced negative dR/dT in two different MXenes with two different intercalant species provides strong evidence that this is a general phenomenon. For sufficient levels of intercalation, the thermally activated inter-flake hopping process becomes the rate-limiting step for conduction through multi-layer samples. This extrinsic effect causes MXenes to display negative dR/dT regardless of their intrinsic electronic properties, as shown schematically in Fig. 2g.

Next, we consider Ti_3CNT_x intercalated with TBA^+ . With annealing, $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$ showed a larger total reduction in resistance than Ti_3CNT_x intercalated with only H_2O and Li^+ (Table 1 and Supplementary Figure 7), consistent with the increased effect of TBA^+ intercalants. However, even after annealing at 750 °C, $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$ continued to display negative dR/dT , albeit with a reduced temperature-dependency (Supplementary Table 1). Given the previous demonstration of metallic intra-flake conduction in Ti_3CNT_x , we speculate that incomplete removal of TBA^+ is responsible for the persistence of the semiconductor-like behavior. After annealing, the temperature-dependent resistance closely followed $R \propto T \times \exp(W/kT)$, which may be related to the inter-flake hopping mechanism (Supplementary Figure 7). It is presently unclear why annealing led to metallic conduction in $\text{Mo}_2\text{TiC}_2\text{T}_x(\text{TBA}^+)$ but not in $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$. This difference could be due to the surface Mo atoms of $\text{Mo}_2\text{TiC}_2\text{T}_x$ affecting the release of TBA^+ and/or the inter-flake hopping process.

Termination. After de-intercalation, vacuum annealing at higher temperatures led to surface de-functionalization and improved electronic conductivity. Initially, each sample had -OH, -F, and =O terminations in varying concentrations (Table 1). Based on DFT calculations, -OH should be the first species to desorb^{12,66}, and for certain samples, TGA-MS data indicated the loss of -OH ($m/e = 17$) at ~375 °C (Fig. 2a). However, for the majority of TGA-MS measurements, the release of de-protonated H_2O completely masked the signal of -OH loss (Supplementary Figure 4). De-functionalization of -OH was also difficult to detect with in situ EELS (Fig. 2b), which could be due to the electron beam transforming -OH groups into more stable =O terminations prior to EELS acquisition⁷². Conversely, the partial loss of -F and =O species were clearly identified. As such, we focus on the effects of -F and =O desorption; however, we stress that the release of these species indicates prior loss of less stable -OH groups^{12,66}.

Annealing $\text{Ti}_3\text{C}_2\text{T}_x$ from 300 to 775 °C led to a significant loss of -F termination species and an associated increase in sample conductivity. In situ EELS measurements show a decrease in the F *K*-edge intensity after annealing at 500, 700, and 775 °C (Fig. 3a), demonstrating the partial de-functionalization of -F. Consistent with the EELS measurements, ex situ TGA-MS shows the release of -F termination ($m/e = 19$) beginning around 400 °C (Fig. 3b). The broad peak in the $m/e = 19$ ion channel at ~150 °C closely mirrors the H_2O channel, indicating that this peak arises from a mechanism related to H_2O de-intercalation, e.g., release of protonated H_2O . Despite the large loss of -F, there was no evidence of =O release, as demonstrated by the constant value of peak 1 of the O *K*-edge EELS spectra (Fig. 3c).

The observed loss of -F beginning at ~400 °C and the retention of =O terminations is consistent with ref. ⁷³, where Persson et al. report in situ annealing of $\text{Ti}_3\text{C}_2\text{T}_x$ with scanning TEM (STEM) and XPS analysis. However, our results differ from the recent in situ STEM annealing of $\text{Ti}_3\text{C}_2\text{T}_x$ reported by Sang et al.⁵⁴. In their study, =O terminations were lost and large voids were formed after 500 °C annealing and electron irradiation. We attribute these contradictory results to beam induced effects. Sang et al. utilized a focused STEM probe ($\sim 10^9 \text{ e}^- \text{ s}^{-1} \text{ \AA}^{-2}$) while we used a spread TEM beam ($\sim 10 \text{ e}^- \text{ s}^{-1} \text{ \AA}^{-2}$). Moreover, our use of low-dose DD EELS⁵³ allows short acquisition times, further decreasing the potential for beam-induced sample degradation (Supplementary Figure 1).

In Fig. 3d, we show the correlation between changes in the $\text{Ti}_3\text{C}_2\text{T}_x$ -F concentration and the RT resistance as a function of annealing temperature. The decrease in sample resistance produced during the 500 °C annealing step likely has a significant contribution from the loss of -OH groups. Additionally, there may be a small contribution from the final stages of H_2O de-intercalation. However, after the 500 °C annealing step, ex situ TGA-MS (Fig. 3b) and in situ EELS (Fig. 3c) show no evidence of further H_2O loss. Additionally, XRD studies have shown that there is no change in the $\text{Ti}_3\text{C}_2\text{T}_x$ *c*-lattice spacing for annealing beyond 500 °C⁷⁴. With no evidence of intercalation loss, no change in the inter-flake spacing, and no observation of a conducting secondary phase (Supplementary Figure 2)⁷⁵, we conclude that the improvement in $\text{Ti}_3\text{C}_2\text{T}_x$ conductivity during annealing steps at 700 and 775 °C is entirely due to the loss of -F terminations.

Similar to $\text{Ti}_3\text{C}_2\text{T}_x$, in situ annealing of Ti_3CNT_x at 500 and 700 °C led to a reduction in -F species and improved conductivity (Fig. 1b and Supplementary Figure 8). In addition to the Ti_3CNT_x sample discussed previously in the text and shown in Figs. 1 and 2, another Ti_3CNT_x sample was measured with time-resolved in situ EELS. The time-resolved measurements of Ti_3CNT_x show the simultaneous release of -F termination species alongside an increase in electronic conductivity (Fig. 3e, f and Supplementary Figure 9). This data further demonstrates that the loss of termination species influences the MXene electronic properties.

For $\text{Mo}_2\text{TiC}_2\text{T}_x$, surface de-functionalization occurred at lower temperatures than $\text{Ti}_3\text{C}_2\text{T}_x$ or Ti_3CNT_x , indicating a weaker interaction between termination species and surface Mo atoms compared to Ti atoms. In situ EELS shows the complete loss of -F from $\text{Mo}_2\text{TiC}_2\text{T}_x$ after annealing at 500 °C (Supplementary Figure 8), and annealing at 700 and 775 °C produced a large reduction in the =O concentration (Fig. 3g). As =O terminations were partially removed from the surface, the $\text{Mo}_2\text{TiC}_2\text{T}_x$ resistance decreased a total of 32% (Fig. 3h). These findings suggest that the release of =O from $\text{Mo}_2\text{TiC}_2\text{O}_x$ increases the MXene intra-flake conductivity^{38,59}. However, we cannot rule out the possibility that inter-flake effects contribute to the measured changes in resistance for annealing steps at 700 and 775 °C. As opposed to H_2O intercalants which cleanly de-intercalate, the TBA^+ intercalants

decompose (Fig. 2e and Supplementary Figure 4). Even though the decomposition of TBA^+ leads to the onset of metallic behavior in $Mo_2TiC_2T_x$ (Fig. 1c), it is possible that some residue remains even after annealing at $>500^\circ C$. This is likely the case for $Ti_3CNT_x(TBA^+)$, since this MXene does not show metallic behavior even after annealing at $750^\circ C$.

To the best of our knowledge, these results constitute the first direct experimental correlation of MXene surface chemistry and electronic conductivity. Previous DFT studies have predicted that termination of $Ti_3C_2T_x$ and Ti_3CNT_x with $-OH$, $-F$ and/or $=O$ significantly alters the electronic states near E_F ^{7,43,55,56,66}. For non-terminated Ti_3C_2 and Ti_3CN , DFT predicts a local maximum in the DOS at E_F , but with complete surface functionalization, the $DOS(E_F)$ is greatly reduced. Consequently, surface functionalization may alter the electronic resistance through a decrease in the carrier concentration, n . To test the validity of this proposed mechanism, we analyzed the concurrent changes in the $Ti_3C_2T_x$ and Ti_3CNT_x resistance and dR/dT with in situ annealing. We assume that the metallic intra-flake conductivity of these MXenes can be described by the Drude equation, and that over the temperature range of our in situ TEM experiments, electron-phonon scattering is approximately linear in temperature (Fig. 1)^{76,77}. With these assumptions, the Drude equation predicts that an increase in n with annealing will produce a proportional decrease in the resistance and dR/dT , i.e., $\Delta R \propto \Delta dR/dT \propto (n_1/n_2 - 1)$, where n_1 and n_2 are the carrier concentrations before and after annealing, respectively (Supplementary Note 1). To visualize this behavior, we define η as the ratio of the proportional change in the RT dR/dT to the proportional change in the RT resistance for a given annealing step. A value of $\eta = 1$ is predicted for a change in resistance driven solely by a change in the intra-flake carrier concentration. For annealing $Ti_3C_2T_x$ and Ti_3CNT_x at high temperatures, $\eta \sim 1$, supporting the claim that surface de-functionalization increases the MXene conductivity through an increase in n (Fig. 4).

In contrast to the $\eta \sim 1$ behavior for high temperature annealing, η is negative for annealing $Ti_3C_2T_x$ and Ti_3CNT_x at low temperatures ($\eta < 0$ reflects a decrease in resistance and an increase in dR/dT). As we describe in Supplementary Note 1, a negative value of η is inconsistent with a change to the intra-flake metallic conductivity driven by, e.g., a change in n , effective electron mass, or defect density. However, a negative value of η can be explained by a decrease in the insulating inter-flake resistance, assuming that the inter-flake and intra-flake resistances act in series. Thus, the observed transition from negative to positive η is indicative of a transition from control over the inter-flake resistance (due to low temperature annealing and de-intercalation) to control over the intra-flake resistance (due to high temperature annealing and surface de-functionalization). For $Mo_2TiC_2T_x$ and $Ti_3CNT_x(TBA^+)$, $\eta < 0$ for all annealing temperatures, suggesting that residue from the TBA^+ decomposition continues to affect the MXene inter-flake resistance even after annealing at $>500^\circ C$ (Supplementary Figure 5).

Discussion

In this study, we vacuum annealed multi-layer MXene samples within the TEM and measured 4, 6, >10 , and 6 times increases in the conductivity of $Ti_3C_2T_x$, Ti_3CNT_x , $Ti_3CNT_x(TBA^+)$, and $Mo_2TiC_2T_x$, respectively. With annealing, we studied de-intercalation and surface de-functionalization with both in situ and ex situ spectroscopic techniques. By correlating this chemical analysis with in situ resistance and dR/dT measurements, we were able to delineate the effects of intercalation and surface termination on MXene electronic properties.

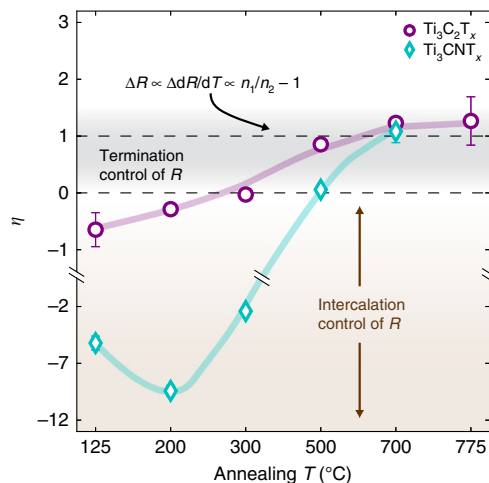


Fig. 4 Analysis of concurrent resistance and dR/dT changes with annealing. For a given annealing step, η is the ratio of the proportional change in the RT dR/dT to the proportional change in the RT resistance (Supplementary Note 1). A positive value of η (indicating a decrease in both the dR/dT and the resistance) is consistent with a change in the intra-flake resistance, and a negative value of η (indicating an increase in dR/dT and a decrease in resistance) is consistent with a change to the inter-flake resistance. For a change in resistance solely due to a change in the intra-flake carrier concentration, the Drude formula predicts that $\eta = 1$. The colored lines are a guide to the eye. Error bars represent the measurement standard error accounting for the linear fit to the dR/dT data and assuming a base uncertainty of 1.2% in the resistance measurements. For the inset equation, n_1 and n_2 refer to the intra-flake carrier concentrations before and after an annealing step, respectively. See Supplementary Figure 5 for dR/dT and η analysis for all studied MXenes

Considering the role of intercalants first, we found that both H_2O and TBA^+ intercalants increase sample resistance and can induce negative dR/dT . Vacuum annealing caused de-intercalation, significant decreases in sample resistance, and the onset of metallic conduction (except for $Ti_3CNT_x(TBA^+)$). The effects of TBA^+ intercalation on electronic properties were far greater than that of H_2O , and even after annealing at $>750^\circ C$, lingering effects of TBA^+ intercalation persisted. These findings are relevant for the optimization of MXene devices where large metallic conductivity is required and the increased inter-flake spacing associated with intercalation does not affect performance, e.g., wireless communication and wearable electronics. The ability to control dR/dT through intercalation could find use in multifunctional sensors or in the development of MXene films with arbitrary dR/dT values. Additionally, we note the striking similarities between the intercalated Ti_3CNT_x and $Mo_2TiC_2T_x$ samples measured here with previous reports of semiconductor-like transport in Mo- and V-based MXenes^{38–40}. Confirmation of intrinsic semiconducting MXene behavior will require temperature-dependent resistance measurements of single-flake MXene devices, which is beyond the scope of this study.

Regarding the effects of termination, vacuum annealing was shown to cause partial surface termination removal and increases in the MXene electronic conductivity. Oxygen terminations were more stable than $-F$ terminations, and $Mo_2TiC_2T_x$ experienced a greater degree of surface de-functionalization than the Ti-based MXenes. These findings provide an avenue to further improve performance in MXene applications such as electromagnetic interference shielding and optoelectronics. For other applications, e.g., triboelectrics and catalysis, improved conductivity is desired, but the functionalized MXene surfaces offer chemical benefits. Hence, further analysis is needed to understand how partial de-

functionalization affects performance in these areas. From a broader perspective, our findings provide a first step towards realizing non-functionalized MXenes and termination-engineered MXenes, which are predicted to exhibit magnetism⁵⁶, fully spin-polarized transport⁴², semiconducting behavior^{36,38}, and non-trivial topological order^{60,78}.

Methods

Syntheses of MXenes. $\text{Ti}_3\text{C}_2\text{T}_x$ MXene was synthesized by selective etching of Ti_3AlC_2 MAX phase (Materials Research Center, Ukraine) in a mixture of LiF and HCl⁶. Specifically, 0.5 g of Ti_3AlC_2 powder was allowed to react with a premixed etchant (0.8 g of LiF and 10 mL of 9 M HCl) for 24 h at room temperature. Then the acid mixture was washed with 150 mL of deionized water for 3–5 cycles until the pH of the supernatant reached the value of 5. After that, the mixture was hand-shaken for 10 min followed by centrifugation at 3500 rpm for 10 min to remove unreacted MAX particles and reaction by-products. The dark supernatant was centrifuged at 3500 rpm for another 1 h to yield delaminated $\text{Ti}_3\text{C}_2\text{T}_x$ solution.

Ti_3CNT_x MXene was synthesized from Ti_3AlCN MAX¹¹ phase by two different routes. For the first route, the synthesis protocol is similar to the $\text{Ti}_3\text{C}_2\text{T}_x$ protocol mentioned earlier except that the reaction mixture was stirred at 500 rpm at 40 °C for 18 h. For the second route, etching is performed in HF acid and delamination is achieved with molecular intercalation. Initially, 2 g Ti_3AlCN was etched in 20 mL of ~30% HF acid for 24 h at room temperature. The reaction mixture was washed with 150 mL of deionized water for 3–5 cycles until the pH of the supernatant reached the value of 5. The resulting mixture was filtered through a filter paper (3501 Coated PP, Celgard, USA) to collect multilayer Ti_3CNT_x powder. To delaminate the Ti_3CNT_x powder, 1 g of dry powder was stirred in a mixture of 9 mL of water and 1 mL of tetrabutylammonium hydroxide (TBAOH) solution (48 wt%, Sigma Aldrich) for 24 h. The mixture was hand-shaken for 10 min and washed with 3–5 cycles of deionized water. After neutral pH was reached, the mixture was centrifuged at 3500 rpm for 10 min to remove unreacted MAX particles and reaction by-products. The brownish supernatant was centrifuged at 3500 rpm for another hour to yield delaminated Ti_3CNT_x solution.

$\text{Mo}_2\text{TiC}_2\text{T}_x$ was synthesized from $\text{Mo}_2\text{TiAlC}_2$ MAX phase⁵⁹. To produce the MAX phase, Mo, Ti, Al, and graphite powders (Alfa Aesar, Ward Hill, MA) were mixed in a ratio 2:1:1.1:2 and ball milled for 18 h in a plastic jar with zirconia balls. The powder mixture was transferred in an alumina crucible and held at 1600 °C for 4 h (5 °C min⁻¹, Ar). The resulting MAX block was drilled and sieved (400 mesh, particle size <38 μm). Specifically, 2 g of $\text{Mo}_2\text{TiAlC}_2$ powder was added to 40 mL of 48–51% aqueous HF solution and stirred at 50 °C for 48 h. The mixture was washed and collected the same way as the HF-prepared Ti_3CNT_x MXene. To delaminate $\text{Mo}_2\text{TiC}_2\text{T}_x$ powder, 1 g of the powder was stirred in 10 mL of 48% TBAOH aqueous solution for 12 h. The mixture was washed with 3 cycles of deionized water (3500 rpm for 15 min, each cycle). After a pH of 7–8 was reached, the supernatant was decanted the same way as the $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$. The sediment was dispersed in 30 mL of deionized water and sonicated for 30 min in a water-ice sonication bath under argon bubbling. The final solution was centrifuged at 3500 rpm for 30 min. Finally, the supernatant is collected.

We note that the exact changes in conductivity, intercalation, and surface termination reported here are likely related to MXene film thickness, flake size, and general flake quality, which are all a function of the synthesis process. As such, the measurement of different MXene films—produced with differing synthesis procedures—will likely produce a differing degree of conductivity changes with annealing.

Electron microscopy and spectroscopy. A JEOL 2100F microscope with a Schottky electron emitter was used for these experiments. The microscope is equipped with the high-resolution pole piece with a C_s of 1 mm. EELS measurements were performed in TEM (diffraction) mode in order to sample a large area of the MXene film and to reduce irradiation-induced sample degradation. The EELS collection angle was set to 11 mrad. A direct detection (DD) EELS system was used as recently reported in ref. ⁵³. The energy dispersion was set to 0.125 eV per channel, and the zero-loss peak (approximate energy resolution) was measured to be ~1.0 eV. For EELS analysis, Gatan DigitalMicrograph was used.

In situ heating and biasing. The DENSSolutions Lighting D9+ heating and biasing sample holder was used for in situ TEM/EELS experiments with the 8 contact (A1-type) heating and biasing nanochips⁶². MXenes were deposited onto the nanochips through spray casting²⁴ (Supplementary Figure 2). A mask was used to confine the MXene deposition to an area centered on the biasing electrodes (Supplementary Figure 2). Resistance measurements were performed with a 4-probe geometry using a Keithley 2400 SMU. Due to the high conductivity of MXene and the large sample cross-sectional area (relative to in situ TEM standards), application of voltages above 0.1 V led to high current densities. The resulting Joule heating strongly affected heating measurements and damaged the heating and biasing chips. As such, the resistance measurements were obtained with applied voltages of ≤5 mV.

The maximum annealing temperatures were 775, 700, 750, and 775 °C, for $\text{Ti}_3\text{C}_2\text{T}_x$, Ti_3CNT_x , $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$, and $\text{Mo}_2\text{TiC}_2\text{T}_x$, respectively. The Ti_3CNT_x samples were not heated to 775 °C since previous experiments showed a larger extent of TiO_2 formation at 775 °C. Heating and cooling rates were 1 °C s⁻¹. For annealing steps performed at 75, 125, and 200 °C, the maximum temperature was held for 10 s, and for annealing steps performed at 300, 500, 700, and 775 °C, the maximum temperature was held for 5 min. We note that the average temperature within the samples deviated from the input temperature due to temperature gradients within the films (Supplementary Figure 10).

A different heating procedure was used for the $\text{Ti}_3\text{CNT}_x(\text{TBA}^+)$ sample. Initially, free TBA^+ molecules prevented good electrical contact, and the sample was annealed in situ at 200 °C to achieve adequate contact between the MXene film and Pt electrodes. Then the sample was heated to 750 °C and held at this temperature for 1 h. This modified procedure was aimed at ensuring maximum de-intercalation/decomposition of the TBA^+ molecules without significant TiO_2 formation.

We note that for each M_{n+1}X_n chemistry, two samples were tested with in situ TEM heating and biasing, and each sample showed qualitatively similar behavior (Supplementary Table 2).

Thermogravimetric-mass spectrometry analysis. Simultaneous thermogravimetric-mass spectrometry analysis was performed on a Discovery SDT 650 model connected to Discovery mass spectrometer (TA Instruments, DE). Vacuum-filtered films of MXenes were cut to small pieces and packed in a 90 μL alumina pan. Before heating, the analysis chamber was flushed with He gas at 100 mL min⁻¹ for 1 h to reduce residual air. The samples were heated to 1500 °C at a constant heating rate of 10 °C min⁻¹ in He atmosphere (100 mL min⁻¹).

Low temperature electronic transport. Electronic transport properties of MXenes after heat treatments were measured in a Quantum Design EverCool II Physical Property Measurement System (PPMS). After the in situ annealing experiments, the heating and biasing nanochip was removed from the TEM and wired to the PPMS sample puck using conductive Ag paint (Supplementary Figure 11). Temperature-dependent resistance was recorded from 25 °C (300 K) down to -263 °C (10 K) in a low pressure helium environment (~20 Torr). Magnetoresistance data was recorded at 10 K by sweeping the magnetic field perpendicular to the chip from -70 kOe to 70 kOe. We note that for both the Ti_3CNT_x and $\text{Mo}_2\text{TiC}_2\text{T}_x$ samples, the room temperature resistance and dR/dT values (but not the sign of dR/dT) differed between the final measurement within the TEM and subsequent measurements within the PPMS. This difference is likely due to the differing experimental set-up and/or sample degradation during exposure to atmosphere after removal from the TEM.

X-ray photoelectron spectroscopy. X-ray photoelectron spectroscopy analysis was performed in a spectrometer (Physical Electronics, VersaProbe 5000, Chanhassen, MN) using a 100 μm monochromatic Al Kα X-ray beam. Photoelectrons were collected by a takeoff angle of 45° between the sample surface and the hemispherical electron energy analyzer. Charge neutralization was applied using a dual beam charge neutralizer irradiating low-energy electrons and ion beam. Vacuum-filtered films were mounted on double-sided tape and were electrically grounded using a copper wire. Prior to data acquisition, an Ar beam operating at 2 kV and 2 μA was used to sputter the sample surface for 2 min. Quantification and deconvolution of the core-level spectra was performed using a software package (CasaXPS Version 2.3.16 RP 1.6). Background contributions to the measured intensities were subtracted using a Shirley function prior to quantification and deconvolution.

X-ray diffraction. The X-ray diffraction data were acquired from vacuum-filtered films of the same solution used for the in situ TEM study. The data were acquired by a diffractometer (Rigaku Smart Lab, USA) with Cu Kα radiation at a step size of 0.03° with 0.6 s dwelling time.

Data availability

The datasets generated and/or analyzed during the current study are available from the corresponding author on reasonable request.

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Author contributions

M.L.T. and Y.G. conceived of the experimental plan. J.L.H. performed the in situ TEM and EELS experiments with assistance from A.C.L., K.H., and Y.P. K.H. synthesized and deposited MXenes samples, performed TGA-MS, PPMS, and XPS measurements. B.A. and D.P. prepared $\text{Mo}_2\text{TiAlC}_2$ and $\text{Mo}_2\text{TiC}_2\text{T}_x$, respectively. Y.P. and J.T.v.O. performed nanochip temperature simulations. J.L.H. prepared the manuscript. All authors reviewed and contributed to the final manuscript.

Additional information

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